Special Issue

Emerging Materials and Devices for Perovskite-Based Technologies

Message from the Guest Editors

This Special Issue, "Emerging Materials and Devices for Perovskite-Based Technologies", seeks to gather stateof-the-art contributions addressing these challenges through novel material synthesis, advanced characterization, and innovative device architectures. Topics of interest include new perovskite compositions (low-lead, lead-free, low-dimensional, and doped systems), defect passivation and interface strategies, scalable deposition techniques, and encapsulation approaches. Contributions on perovskite-based photovoltaics, LEDs, photodetectors, catalytic systems, and energy-storage devices are highly encouraged. Studies involving computational modeling, machine learning, and in situ/operando methods applied to understand degradation and improve device reliability are also welcome. By combining fundamental insights and applied research, this Special Issue aims to outline pathways toward robust, sustainable, and commercially relevant perovskite technologies.

Guest Editors

Dr. Arian Espinosa Roa

Dr. Mirna Denisse Barreiro-Argüelles

Prof. Dr. Edgar González-Juárez

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Processes
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
processes@mdpi.com

mdpi.com/journal/ processes





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Message from the Editor-in-Chief

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Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

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